# CHAPTER - 5

# **ELECTRON SPIN RESONANCE**

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Electron Spin Resonance (ESR) or Electron Paramagnetic Resonance (EPR) is a physical method of observing resonance absorption of microwave power by un-paired electron spins in a magnetic field. ESR was discovered by Zavoisky in 1945 for transition metal ions in salts and developed after world war-II using advances in microwave and solid-state electronics. The fundamentals of the technique, its parameters and methods of interpreting the results are given in the following text.

#### 5.1 Electron spin

Classically an electron considered to be negatively charged, rotating sphere. This rotation produces a circulating current in the direction opposite to the rotation of the sphere. The circular current produces a magnetic field in the vicinity of the electron. Therefore, the electron spin (self rotation) can be considered equivalent to a tiny magnet Fig-5A. Such magnets form magnetically neutral pairs in atoms and molecules Fig-5A(a). No net magnetic moment is present due to the neutralizing effects of the pairing of electron spins in most materials. Natural or artificial radiation ionizes atoms or molecules, i.e. breaks the paired electron Fig-5A(b). When some other atoms trap the ionized electron, an electron-excess atom and an electrondeficient atom are formed: the former and the latter, both with an unpaired electron, are called "trapped electron" and "trapped hole" center, respectively. They now have net magnetic moment  $\mu_e$  due to the unpaired electron spins. An unpaired electron may be considered as a tiny magnet Fig-5A(c). Unpaired spins tend to align parallel to the direction of a magnetic field and magnetize. Hence the word "electron paramagnetism" is used for magnetic properties arising from unpaired electrons in a material. They are detectable with microwave absorption spectroscopy under an



Fig-5A: (a) Paired electron and radiation (b) Ionization (c) Formation of unpaired electrons.

external magnetic field called "Electron Paramagnetic Resonance (EPR)" or "Electron Spin Resonance (ESR)".

#### 5.2 Fundamental principle of ESR

When spinning electrons are placed in an external static magnetic field, the direction of a small magnet, i.e. the direction of spin rotation which is initially random becomes either the same or opposite to that of the external magnetic field. These two situations are energetically different and are called 'up spin' and 'down spin' states. The electron spin excited from the lower energy level by the absorption of the microwave quanta flop to the lower level by the lattice vibration in a time called the spin lattice relaxation time (T<sub>1</sub>). Flopping of the spins also occurs due to the interaction among spins and this flopping time is called the spin-spin relaxation time (T<sub>2</sub>). If the microwave power is so high as to pump out the spins in the lower level or the relaxation time is too long for the population to be restored, a decrease in signal intensity is observed. This is called "saturation". The magnetic properties of unpaired electrons are expressed by following parameters.

- Spin angular momentum: S (h/ $2\pi$ ) h = Planck constant
- Spin quantum number: S = 1/2 for an electron
- Magnetic quantum number: M = 1/2 and -1/2 are allowed.
- Bohr Magneton: B the basic units of a small factor magnet for an electron spin.

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- Magnetic moment  $\mu$ :  $\mu_e = -gBS$
- Spectroscopic splitting factor g = 2.0023 for a free electron.
  - H in Tesla ( $T = 1T = 10^4$  gauss) or in mT (1mT = 10 gauss)

#### 5.3 ESR spectra and parameters

• Line shape: Gaussian and Lorentzian shapes

- g-factor
- Anisotropic g-factors and random orientation.
- Hyperfine (hf) Structure
- Proton hyperfine structure: Equivalent-protons
- Mcconnell's Relation
- Superhyperfine (shf) Structure
- Fine Structure

**g-factor** - The spectroscopic splitting factor, the g-factor of an ESR signal, is an important parameter, since unpaired electrons in different environments have slightly different g-factors, resulting in the appearance of signals for different centers at different magnetic field strengths. Classically, the slight g-factor change due to the environment might be ascribed to the change of the effective negative charge by the spread of the electron wave function. The g-factor is determined by,

$$g = (h/B)(v/H) = 71.455 \times v/H$$

Where, the microwave frequency v (in GHz) and magnetic field H (in mT) are measured with a frequency counter and a field meter, respectively. The g-factor of the unknown signal is determined using a standard signal with a known g-factor. If resonance of standard signal with  $g_1$  and unknown signal with  $g_2$  occurs at  $H_{o1}$  and  $H_{o2}$  respectively (the magnetic field separation  $\Delta H = H_{o1}$ -  $H_{o2}$ ), the resonance condition gives

$$g_{1}H_{o1} = g_{2}H_{o2} = h\nu/B$$
  

$$g_{2} = g_{1}H_{o1}/H_{o2} = h\nu/B$$
  

$$g_{2} = g_{1}H_{o1}/H_{o1} - \Delta H = h\nu/B \text{ where, } \Delta H = H_{o1} - H_{o2}$$
  

$$g_{2} = g_{1}/1 - \Delta H/H_{o1}$$

Usually, the resonance field (H<sub>o</sub>), falls around 340mT for v = 9.4GHz

ESR signal is defined by the "g-factor" and hence the g-factor are generally around 2.0 and are usually determine to the decimal place with a probable error of  $0.0002 \sim 0.0005$ .

Now a brief account of defects patterns in  $SiO_2$ , which are identified by ESR technique, is presented in following discussions.

Normal Lattice  $: [SiO_4]^\circ, SiO_4^{-4} \text{ or } \equiv Si-O-Si \equiv$ 

## (a) Intrinsic Defects

$E_1$ ' center	$: [SiO_3]^+, SiO_3^{-3} \text{ or } \equiv Si \cdot Si \equiv$
Peroxy center	: $[SiO_5]^-$ , $SiO_5^{-5}$ or $\equiv$ Si-O(-O <sup>•</sup> )-Si $\equiv$ g <sub>1</sub> - 2.0014, g <sub>2</sub> - 2.0074, g <sub>3</sub> - 2.0067
NBOHC	: $[SiO_4]^+$ , $SiO_4^{-3}$ or $\equiv$ Si-O <sup>•</sup> , g <sub>1</sub> - 2.0010, g <sub>2</sub> - 2.0095, g <sub>3</sub> - 2.078
OHC(O <sub>3</sub> <sup>-</sup> ?)	: O-O-O <sup>•</sup> $g_1 - 2.011 - 2.012$

Oxygen Vacancies:  $[SiO_3]^{+2}$ ,  $SiO_3^{-2}$  or  $[V^-]^{+2}$ ,  $[SiO_3]^{\circ}$ ,  $SiO_3^{-4}$  or  $[V-2e^-]^{\circ}$ 

The following three pairs are considered in SiO<sub>2</sub> Fig-5B(a to e). A pair oxygen vacancy [V.] and interstitial  $O^{-2}$  is not stable at room temperature. 'b' and 'd'. A paired E<sub>1</sub>' center (an electron at an Oxygen vacancy) and peroxy center (interstitial  $O^{\bullet}$ ) is stable and is observed in natural quartz and irradiated amorphous-SiO<sub>2</sub>. 'c' and 'e'. A paired Si vacancy and Si interstitial is energetically not stable. A paired anion ( $O^{-2}$ ) vacancy and cation (Si<sup>+4</sup>) vacancy called "Schottky Pair" is negligible around room temperature unless SiO<sub>2</sub> is quenched from high temperature. The detail information about E<sub>1</sub>' and Ge center are only presented as it is related with the present work.



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# E<sub>1</sub>' Center: g<sub>1</sub>- 2.00179, g2-2.00053, g3-2.00030

Model: The simplest point defect in quartz is an electron at the oxygen vacancy called the  $E_1$ ' center. The model for the  $E_1$ ' center in amorphous and crystalline SiO<sub>2</sub> is an unpaired electron in a dangling sp<sup>3</sup> hybrid orbital of pyramidal SiO<sub>3</sub><sup>-3</sup> where an oxygen ion O<sup>-</sup> is extracted from a SiO<sub>4</sub> tetrahedron. The production of the  $E_1$ ' center is shown in **Fig-5B** 'a' to 'c'.

Thermal Property: The signal intensity of  $E_1$ ', center is increased above 200°C at the expense of the hole type Al-center. It is annealed about at 360°C to 380°C and regeneration efficiency is strongly reduced by annealing at 500°C. Presumably, high temperature annealing annihilates oxygen vacancies around dislocations or in  $\alpha$ -recoil tracks. From the annealing and saturation properties, two types of  $E_1$ ', centers have been proposed, one is annealed around 200°C in an artificially irradiated sample, while the other is stable up to around 360°C.

Microwave Power dependence: The signal intensity of the  $E_1$ ' center is easily saturated at a microwave power of  $10^2$ mW.

## (b) Impurity-Associated Defects

Al-center: Al-related hole center -  $[AlO_4]^{\circ}$ ,  $[Al^{+3} h^+]^{\circ}$ ,  $AlO_4^{-4}$ , = Al-O<sup>•</sup> Ge-center: Ge-related electron center -  $[GeO_4/Li]_c^{\circ}$ ,  $[Ge^{+4} e^-/Li^+)_c^{\circ}$ ,

 $GeLiO_4^{-4}(=Ge-O_{-})^{-} - Li^{+}$ 

Ti-center: Ti-related electron center -  $[TiO_4/Li]_A^\circ$ ,  $[Ti^{+4} - e^-/Li^+]_A^\circ$ ,  $TiLiO_4^{-4}$ or (= Ti-O<sup>-</sup>) -  $Li^+$ 

ESR spectra of natural crystalline-SiO<sub>2</sub> powder show signals associated with impurities. Electron (or hole) trapped by impurities gives ESR signals associated with impurities such as substitutional tetravalent ions (Ge<sup>+4</sup> and Ti<sup>+4</sup>) and trivalent ion (Al<sup>+3</sup>) as well as interstitial monovalent cation,  $M^+(H^+, Li^+ and Na^+)$ . ESR spectra of the Al-related hole center and Ge and Ti-related electron centers in natural crystalline SiO<sub>2</sub>.

Ge Center  $[GeO_4/M^+]_c^{\circ}:(M = Li): g_1-2.0000, g_2 - 1.9973, g_3 - 1.9962$ 

Model: Isoelectronic Ge<sup>+4</sup> substitutes for a Si<sup>+4</sup> site the SiO<sub>2</sub> lattice but its electrons affinity (ionization potential) is considerably larger, resulting in trapping of an electron created by ionizing irradiated to form [GeO<sub>4</sub>-e<sup>-</sup>]<sup>-</sup> in the SiO<sub>2</sub> lattice. The total charge of the center is -1 and thus Ge<sup>+3</sup> at a Si<sup>+4</sup> site in an SiO<sub>2</sub> structure has a negative effective charge attracting an interstitial monovalent cation M<sup>+</sup> such as H<sup>+</sup>, Li<sup>+</sup> of Na<sup>+</sup> to form stable [GeO<sub>4</sub>/M<sup>+</sup>]<sup>o</sup> at room temperature. The process is summarized as follow.

 $Ge^{+4}$  (irradiation) (stabilized by M<sup>+</sup> at RT)  $[SiO_4]^{\circ} \rightarrow [GeO_4]^{\circ} \rightarrow [GeO_4-e]^- \rightarrow [GeO_4-e-/M^+]^{\circ}$ ESR signal of the Ge center appears at the high field side of the E<sub>1</sub>' center. Microwave power dependence. The Ge center saturated at high microwave power (>100mW). Ge center is annealed out at 250°C - 280°C.<sup>3</sup>

#### 5.4 Results and Discussion

Aim of the present work concerns with ESR to confirm the nature of centers in quartz, which shows changes in the characteristics of TL/OSL curve under different protocols. Finer grains of quartz (230-270mesh), which were exposed to gamma dose of 1000Gy, have been studied for ESR studies also.

Materials were kept between two-magnet poles to create magnetic field and corresponding ESR spectra were plotted at room temperature. ESR experiments were carried out on a Varian E-112 E-line Century series ESR spectrometer with 100kHz field modulation. Tetracynoethylene (TCNE, g = 2.00277) was used as a standard for the g-factor measurements. The following series of experiments were conducted:

1.ESR measurements at room temperature for thermally untreated, but given different gamma doses specimen (spectra-I)

2. Measurements for ESR intensities at room temperature for thermally untreated as well as thermally pre-heat treated specimens (at 600°C) for a higher gamma dose (1000Gy)(spectra-II).

3. ESR measurements at room temperature of specimens thermally pre-heat treated at different temperature (400°C and 1000°C)(**spectra-III and IV**).

4. ESR measurements for the specimens thermally untreated and pre-heat treated at different temperature before UV bleaching (spectra-V(a) and V(b)).

5. ESR measurements for the specimens thermally untreated and pre-heat treated at different temperature after UV bleaching (spectra-VI(a) and VI(b)).

ESR spectra recorded at room temperature for the thermally untreated specimens, when given different gamma exposures; show a center exhibiting an axially systematic g-tensor. The amplitude of this center saturated for a microwave power above 0.1mW, (it is clear form the ESR data for 5mW). The amplitude of this center grows with given dose. The center has been assigned to  $E_1$ ' center namely on the basis of the observed g-value and microwave power dependence. The observed g values (~2.0017) for the present work were reasonably consistent with the ones previously reported by Jani et al., (g = 2.0018, 2.0005, 2.0003)<sup>1</sup> and P.G.Benny et al.<sup>2</sup>

In the present experiments, the other two signals at higher magnetic fields could not be resolved possibly due to large modulation width. The ESR results are parallel with the growth in TL and OSL sensitivity with increase in dose under other identical physical conditions. Further, thermally untreated materials were exposed to high gamma dose of 1000Gy. It was noticed that along with the saturation in center for higher microwave power,



**ESR Spectra-I** ESR spectra recorded at room temperature of unannealed sample for 230-270mesh at different gamma doses.

(1) Unannealed, unirradiated, 0.1mW (2) Unannealed, 20Gy, 0.1mW (3) Unannealed, unirradiated, 5mW (4) Unannealed, 20Gy, 0.1mW (5) Unannealed, 320Gy, 0.1mW (6) Unannealed, 320Gy, 5mW.



**ESR Spectra-II** ESR spectra recorded at room temperature of unannealed and 600°C sample for 230-270mesh at a constant gamma dose of 1000Gy. (1) Unannealed, 0.1mW (2) Unannealed, 5mW (3) Unannealed, 5mW (4) 600°C annealed, 0.1mW (5) 600°C annealed, 5mW.



ESR Spectra-III ESR spectra recorded at room temperature of 400°C and 1000°C annealed sample for 230-70mesh at a given gamma dose of 600 Gy. (1) 400°C annealed, 0.1mW (2) 400°C annealed, 5mW (3) 400°C annealed,5mW (4)1000°C annealed, 0.1mW.



ESR Spectra-IV ESR spectra recorded at room temperature of 1000°C annealed sample for 230-70mesh at constant gamma dose of 1000 Gy.

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**ESR Spectra-V(a)** ESR spectra recorded at room temperature before UV illumination for  $E_1$ ' Center of unannealed and annealed sample for 230-70mesh at a given gamma dose of 1000 Gy.

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**ESR Spectra-V(b)** ESR spectra recorded at room temperature before UV illumination for Ge Center of unannealed and annealed sample for 230-70mesh at a given gamma dose of 1000 Gy.



**ESR Spectra-VI(a)** ESR spectra recorded at room temperature after UV illumination for  $E_1$ ' Center of unannealed and annealed sample for 230-70mesh at a given gamma dose of 1000 Gy.



**ESR Spectra-VI(b)** ESR spectra recorded at room temperature after UV illumination for Ge Center of unannealed and annealed sample for 230-70mesh at a given gamma dose of 1000 Gy.

ESR signal enhances. To understand the influence of pre-heat treatment on the specimen, ESR spectra were also recorded for thermally pre-heat treated specimens at different of annealing followed by an identical gamma exposure. This protocol is having same schedule as the experiments were carried out for TL/OSL studies (**spectra-I**, **II**, **III** and **IV**).

Here, it was noticed that the specimens pre-heat treated at 400°C exhibits weaker  $E_1$ ' signal as compared to thermally untreated specimens, however it was also observed that a new center was exhibited at higher microwave power (~5mW). That center has been suggested to be Ge center. Again it is mainly on the basis of observed g-values in the present work and corresponding well established report by the others.<sup>3</sup> On further investigations it is pointed out that the ESR signal corresponding to this center grows with the increase in temperature of annealing. This center doesn't saturate up to 5mW microwave power.

To understand and correlate the bleaching/charge transfer effects on the center, the ESR spectra were recorded before and after the sun exposure of the specimens for thermally untreated as well as pre-heat treated at elevated temperatures. It was observed that the amplitude of  $E_1$ ' center reduces remarkably from 6.1 to 4.6a.u after the sun exposure for thermally untreated, 1000Gy dose specimens (**spectra-V(a)** and **VI(a)**). But this center disappears for the specimens pre-heat treated beyond 600°C, even before sun exposures (**spectra-V(a)**). To resolve the Ge center, the ESR was recorded for 5mW microwave power under similar experimental conditions. Such center shows reduction in ESR signal for thermally untreated specimen, whereas significant enhancement is observed in these centers from 6.1 to 8.2 and 6.7 to 7.7a.u for 600°C and 1000°C annealed specimens before and after UV illumination respectively (**spectra-V(b)** and **VI(b)**). The thermally untreated material shows saturation with a very low ESR signal compare to annealed material which is attributed to effect of prethermal treatment, such treatment is responsible for changes in OSL/TL properties of quartz specimen. From present investigation of ESR study it is concluded that the  $E_1$ ' and Ge centers play predominant role in the production of TL peaks at 110°C and 220°C. Bleaching study of ESR signal indicate that the reduction of  $E_1$ ' center and growth of Ge center are correlated with enhancement of 210°C-230°C TL peak in material after optical stimulation. These results also may be attributed to Mckeever et al., who suggested that there were two recombination centers and an electron traps were (GeO<sub>4</sub>)<sup>-4</sup> The recombination centers were identified as holes trapped at (AlO<sub>4</sub>)° and (H<sub>3</sub>O<sub>4</sub>)° centers.<sup>4</sup> Thus ESR spectra strongly correlate with TL glow curve pattern as well as, optical bleaching properties of synthetic quartz specimens.

## References

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